

Form 1449 (Modified) Information Disclosure Statement By Applicant (Use Several Sheets if Necessary)	Atty Docket No. DGMMP001C3	Application No.: NEW
	Applicant: Wong et al.	
	Filing Date HEREWITH	Group UNASSIGNED

JC978 U.S. PTO
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U.S. Patent Documents

Examiner Initial	No.	Patent No.	Date	Patentee	Class	Sub- class	Filing Date
CA	A1	Re33417	10/0	Bhagat et al.			
	A2	Re32365	5/87	Sebestyen			
	A3	4,224,150	9/80	Neustein			
	A4	4,345,491	8/92	Fascenda et al.			
	A5	4,644,347	2/87	Lucas et al.			
	A6	4,644,351	2/87	Zabarsky et al.			
	A7	4,713,808	12/87	Gaskill et al.			
	A8	4,747,122	5/88	Bhagat et al.			
	A9	4,823,123	4/89	Siwiak			
	A10	4,845,491	7/89	Fascenda et al.			
	A11	4,870,402	9/89	DeLuca et al.			
	A12	4,875,038	10/89	Siwiak et al.			
	A13	4,882,579	11/89	Siwiak			
	A14	4,914,649	4/90	Schwendeman et al.			
	A15	4,940,963	7/90	Gutman et al.			
	A16	4,978,944	12/90	Andros et al.			
CA	A17	5,043,721	8/91	May			
	A18	5,086,501	2/92	DeLuca et al.			
	A19	5,109,400	4/92	Patsiokas et al.			
	A20	5,111,197	5/92	Ichikawa			
	A21	5,117,449	5/92	Metroka et al.			
	A22	5,142,279	8/92	Jasinski et al.			
	A23	5,153,580	10/92	Davis			
	A24	5,170,487	12/92	Peek			
	A25	5,206,855	4/93	Schwendeman et al.			
	A26	5,224,150	6/93	Neustein			
	A27	5,247,700	9/93	Wohl et al.			
CA	A28	5,260,986	11/93	Pershan			
	A29	5,285,496	2/94	Frank et al.			
	A30	5,396,496	3/95	Ito et al.			
	A31	5,396,537	3/95	Schwendenman et al.			
	A32	5,463,675	10/95	Gerszberg			
CA	A33	5,485,463	1/96	Godoroja			

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<i>CA</i>	A34	5,491,469	2/96	Schwendeman	<input checked="" type="checkbox"/>	<input checked="" type="checkbox"/>	<input checked="" type="checkbox"/>
<i>CA</i>	A35	5,542,115	7/96	Wong et al.	<input checked="" type="checkbox"/>	<input checked="" type="checkbox"/>	<input checked="" type="checkbox"/>

Foreign Patent or Published Foreign Patent Application

Examiner Initial	No.	Document No.	Publication Date	Country or Patent Office	Class	Sub- class	Translation	
							Yes	No
	J							
	K							
	L							
	M							
	N							

Other Documents

Examiner Initial	No.	Author, Title, Date, Place (e.g. Journal) of Publication
	O	
	P	
	Q	
Examiner	<i>Ch Appah</i>	Date Considered <i>12/23/03</i>

Examiner: Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.